

Product Datasheet

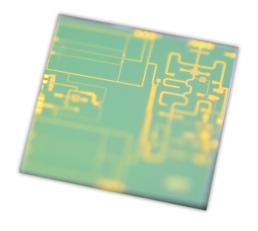
KKa-LNA-1929

GaAs PHEMT MMIC Low Noise Amplifier 17-21 GHz & 27-31 GHz.

Overview

KKa-LNA-1929 is a 3-stage MMIC low noise amplifier that covers frequencies from 17 GHz to 21 GHz and from 27 GHz to 31 GHz. This MMIC provides up to 20 dB of stable gain, with a noise figure of 2.5 dB from a 4 V supply voltage and 41 mA current. By incorporating a self-biased configuration the MMIC provides enhanced temperature stability with no need for a negative supply voltage.

The MMIC is fully passivated for additional protection and has all bond pads and backside gold plated. It is compatible with precision die attach methods, as well as thermo-compression and thermosonic wire bonding, making it ideal for MCM and hybrid microcircuit applications. All data shown is measured with the chip in a 50 Ohm environment, with 100 pF decoupling capacitors on all DC connections and is contacted using RF probes.





- 17-21 GHz & 27-31 GHz frequency ranges
- 20 dB gain
- 2.5 dB noise figure
- Unconditionally stable
- No negative DC supply requirement



- · High speed data communications
- Space communications
- IOT
- Security
- 5G



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Specification Overview

Parameter	Min	Тур	Max	Unit
Operational Frequency Range	17		21	GHz
Gain	21	21.6	22.5	dB
Input Return Loss	10	20		dB
Output Return Loss	5.5	8		dB
Noise Figure		2.5	3.2	dB
Operational Frequency Range	27		31	GHz
Gain	16	20	24	dB
Input Return Loss	6	7		dB
Output Return Loss	8	10		dB
Noise Figure		2.5	3.5	dB
Drain Voltage		4		V
Current		41		mA

The tests indicated have all been performed with 100pF de-coupling capacitors on all bias pads. All tests are carried out at 25 $^{\circ}$ C.

Absolute Maximum Ratings

Parameter	Rating
Drain Voltage	6 V
Drain Current	132 mA
RF Input Power	7 dBm
Storage Temperature	-65 °C to +150 °C
Channel Temperature	+150 °C
Operating Temperature	-40 °C to +85 °C

ESD (electrostatic discharge) sensitive device. Charged devices and circuit boards can discharge without detection. Although this product features proprietary protection circuitry, damage may occur on devices subjected to ESD. Proper ESD precautions should be taken to avoid performance degradation or loss of functionality.

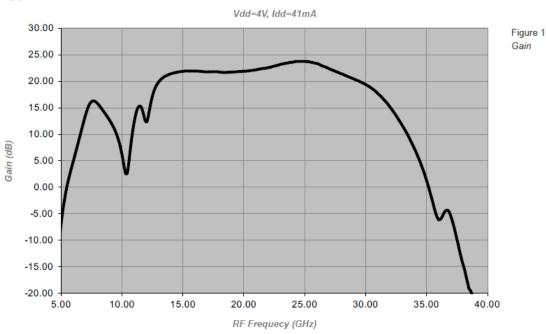
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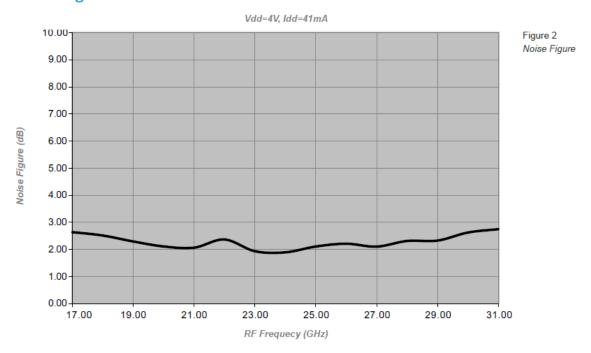
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Measured Performance Data

Gain



Noise Figure

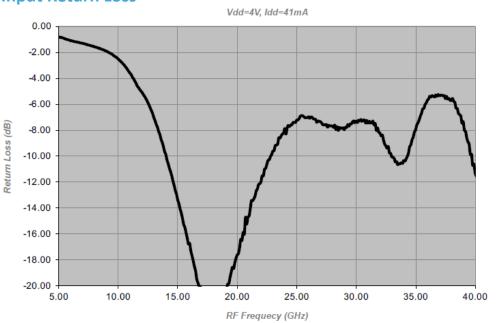


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Input Return Loss



Input Return Loss

Figure 3

Output Return Loss

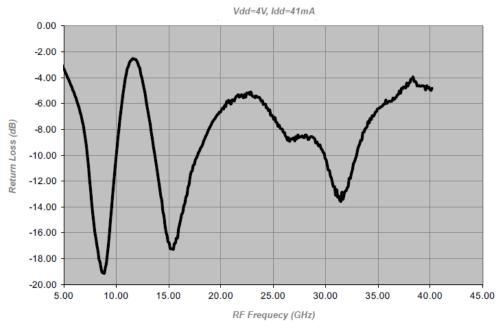


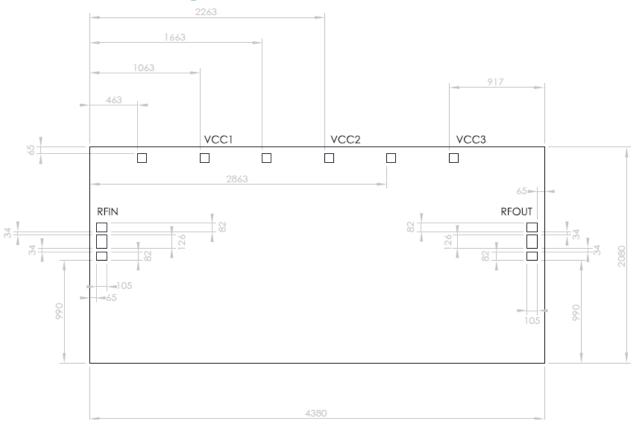
Figure 4	
Output Return Loss	,

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Outline drawing



Notes

- 1. All dimensions are in um
- 2. Typical DC bond pads are 80 um square
- 3. RF bond pads are 105 x 120 um
- 4. All pads have gold metallisation
- 5. Gold backside metallisation
- 6. Backside metal is ground
- 7. Connections are not required for unlabelled bond pads
- 8. Die thickness is 100 um

Die Packing Information

All die delivered using gel-packs unless otherwise requested.

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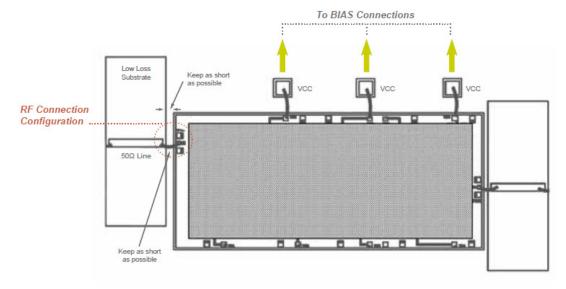


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Pad Descriptions

Name	Description		
RFIN	Input RF pad. This pad is AC coupled		
RFOUT	Output RF pad. This pad is AC coupled.		
VCCx	Drain bias pad for stage x.		
воттом	The die backside must be connected to RF/DC ground.		

Connection Configurations



(Not actual die – these rules are applied to all MMICs unless otherwise stated)

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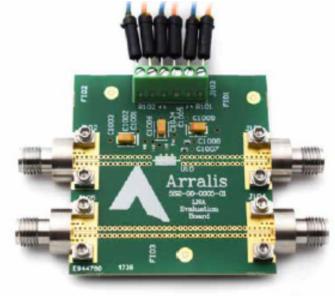
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General Notes On Assembly

Die should be mounted on conductive material such as gold-plated metal to provide a good ground and suitable heat sink, if necessary.

- 1. Attaching the die using Au/Sn preforms is preferable. The Eutectic melt for Au/Sn occurs at approximately 280°C so the die (plus mount and preform) is initially heated up to 180°C and then it is heated for approximately 10 seconds to 280°C using a nitrogen heat gun. The device will survive 10 seconds at this temperature. The static breakdown for GaAs devices is approximately 330°C.
- 2. Pure, dry nitrogen should be used as the heat source.
- 3. If the devices cannot be lifted/ placed by a vacuum device, then ESD die-lifting tweezers are preferable.
- 4. Supply lines should be decoupled with 100pF capacitors. Larger planar capacitors could be used if available.
- 5. Aluminium wire must not be used.

Application Circuit



Evaluation boards are available on request.

Contact Information

ReliaSat European Offices

e: sales@reliasat.com

www.reliasat.com

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